Provisional Data Sheet No. PD-9.1415

International
IOR Rectifier

REPETITIVE AVALANCHE AND dv/dt RATED HEXFET® TRANSISTOR

IRHM9160
P-CHANNEL
RAD HARD

-100 Volt, 0.087Ω, RAD HARD HEXFET

International Rectifier's P-channel RAD HARD technology HEXFETs demonstrate excellent threshold voltage stability and breakdown voltage stability at total radiation doses as high as 10^5 Rads (Si). Under **identical** pre- and post-radiation test conditions, International Rectifier's P-channel RAD HARD HEXFETs retain **identical** electrical specifications up to 1 x 10^5 Rads (Si) total dose. No compensation in gate drive circuitry is required. These devices are also capable of surviving transient ionization pulses as high as 1 x 10^{12} Rads (Si)/Sec, and return to normal operation within a few microseconds. Single Event Effect, (SEE), testing of International Rectifier's P-channel RAD HARD HEXFETs has demonstrated virtual immunity to SEE failure. Since the P-channel RAD HARD process utilizes International Rectifier's patented HEXFET technology, the user can expect the highest quality and reliability in the industry.

P-channel RAD HARD HEXFET transistors also feature all of the well-established advantages of MOSFETs, such as voltage control, very fast switching, ease of paralleling and temperature stability of the electrical parameters.

They are well-suited for applications such as switching power supplies, motor controls, inverters, choppers, audio amplifiers and high-energy pulse circuits in space and weapons environments.

Product Summary

Part Number	BV_{DSS}	$R_{DS(on)}$	I_D
IRHM9160	-100V	0.087 Ω	-35*A

Features:

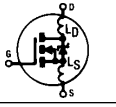
- Radiation Hardened up to 1 x 10^5 Rads (Si)
- Single Event Burnout (SEB) Hardened
- Single Event Gate Rupture (SEGR) Hardened
- Gamma Dot (Flash X-Ray) Hardened
- Neutron Tolerant
- Identical Pre- and Post-Electrical Test Conditions
- Repetitive Avalanche Rating
- Dynamic dv/dt Rating
- Simple Drive Requirements
- Ease of Paralleling
- Hermetically Sealed
- Electrically Isolated
- Ceramic Eyelets

Absolute Maximum Ratings

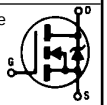
Pre-Radiation

	Parameter	IRHM9160	Units
I_D @ V_{GS} = -12V, T_C = 25°C	Continuous Drain Current	-35*	A
I_D @ V_{GS} = -12V, T_C = 100°C	Continuous Drain Current	-22	
I_{DM}	Pulsed Drain Current ①	-140	
P_D @ T_C = 25°C	Max. Power Dissipation	250	W
	Linear Derating Factor	2.0	W/K ⑤
V_{GS}	Gate-to-Source Voltage	±20	V
E_{AS}	Single Pulse Avalanche Energy ②	500	mJ
I_{AR}	Avalanche Current ①	-35	A
E_{AR}	Repetitive Avalanche Energy ①	25	mJ
dv/dt	Peak Diode Recovery dv/dt ③	-5.5	V/ns
T_J T_{STG}	Operating Junction Storage Temperature Range	-55 to 150	°C
	Lead Temperature	300 (0.063 in. (1.6mm) from case for 10 sec.)	

Electrical Characteristics @ Tj = 25°C (Unless Otherwise Specified)

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
BV_{DSS}	Drain-to-Source Breakdown Voltage	-100	—	—	V	V_{GS} = 0V, I_D = -1.0 mA
$\Delta BV_{DSS}/\Delta T_J$	Temperature Coefficient of Breakdown Voltage	—	-0.13	—	V/°C	Reference to 25°C, I_D = -1.0 mA
$R_{DS(on)}$	Static Drain-to-Source On-State Resistance	—	—	0.087	Ω	V_{GS} = 12V, I_D = -22A ④
		—	—	0.10		V_{GS} = 12V, I_D = -35A ④
$V_{GS(th)}$	Gate Threshold Voltage	-2.0	—	-4.0	V	V_{DS} = V_{GS}, I_D = -1.0 mA
g_{fs}	Forward Transconductance	10	—	—	S (℧)	V_{DS} > 15V, I_{DS} = -22A ④
I_{DSS}	Zero Gate Voltage Drain Current	—	—	-25	µA	V_{DS} = 0.8 x Max Rating, V_{GS} = 0V
		—	—	-250		V_{DS} = 0.8 x Max Rating, V_{GS} = 0V, T_J = 125°C
I_{GSS}	Gate-to-Source Leakage Forward	—	—	-100	nA	V_{GS} = -20V
I_{GSS}	Gate-to-Source Leakage Reverse	—	—	100		V_{GS} = +20V
Q_g	Total Gate Charge	—	—	200	nC	V_{GS} =12V, I_D = -35A
Q_{gs}	Gate-to-Source Charge	—	—	50		V_{DS} = Max. Rating x 0.5
Q_{gd}	Gate-to-Drain ("Miller") Charge	—	—	90		
$t_{d(on)}$	Turn-On Delay Time	—	—	70	ns	V_{DD} = -50V, I_D = -35A,
t_r	Rise Time	—	—	240		R_G = 2.35Ω
$t_{d(off)}$	Turn-Off Delay Time	—	—	220		
t_f	Fall Time	—	—	150		
L_D	Internal Drain Inductance	—	8.7	—	nH	Measured from the drain lead, 6mm (0.25 in.) from package to center of die.
L_S	Internal Source Inductance	—	8.7	—		Measured from the source lead, 6mm (0.25 in.) from package to source bonding pad.
						Modified MOSFET symbol showing the internal inductances. 
C_{iss}	Input Capacitance	—	7000	—	pF	V_{GS} = 0V, V_{DS} = -25V
C_{oss}	Output Capacitance	—	2000	—		f = 1.0 MHz
C_{rss}	Reverse Transfer Capacitance	—	500	—		

Source-Drain Diode Ratings and Characteristics

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
I_S	Continuous Source Current (Body Diode)	—	—	-35	A	Modified MOSFET symbol showing the integral reverse p-n junction rectifier. 
I_{SM}	Pulse Source Current (Body Diode) ①	—	—	-140		
V_{SD}	Diode Forward Voltage	—	—	-3.3	V	T_j = 25°C, I_S = -35A, V_{GS} = 0V ④
t_{rr}	Reverse Recovery Time	—	—	775	ns	T_j = 25°C, I_F = -35A, di/dt ≤ -100A/µs
Q_{RR}	Reverse Recovery Charge	—	—	5.0	µC	V_{DD} ≤ -50V ④
t_{on}	Forward Turn-On Time	Intrinsic turn-on time is negligible. Turn-on speed is substantially controlled by L_S + L_D.				

Thermal Resistance

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
R_{thJC}	Junction-to-Case	—	—	0.50	K/W⑤	
R_{thJA}	Junction-to-Ambient	—	—	48		

Radiation Performance of P-Channel Rad Hard HEXFETs

International Rectifier Radiation Hardened HEXFETs are tested to verify their hardness capability. The hardness assurance program at International Rectifier uses two radiation environments.

Every manufacturing lot is tested in a low dose rate (total dose) environment per MIL-STD-750, test method 1019. International Rectifier has imposed a standard gate voltage of -12 volts per note 6 and a V_{DSS} bias condition equal to 80% of the device rated voltage per note 7. Pre- and post-radiation limits of the devices irradiated to 1 x 10^5 Rads (Si) are identical and are presented in Table 1. The values in Table 1 will be met for either of the two low dose rate test circuits that are used.

Both pre- and post-radiation performance are tested and specified using the same drive circuitry and test conditions in order to provide a direct comparison. It should be noted that at a radiation level of 1 x 10^5 Rads (Si), no change in limits are specified in DC parameters.

High dose rate testing may be done on a special request basis, using a dose rate up to 1 x 10^{12} Rads (Si)/Sec.

International Rectifier radiation hardened P-Channel HEXFETs are considered to be neutron-tolerant, as stated in MIL-PRF-19500 Group D. International Rectifier P-Channel radiation hardened HEXFETs have been characterized in heavy ion Single Event Effects (SEE) environment and results are shown in Table 3.

Table 1. Low Dose Rate ⑥ ⑦

Parameter		IRHM9160 100K Rads (Si) min.	IRHM9160 100K Rads (Si) max.	Units	Test Conditions ⑩
BV_{DSS}	Drain-to-Source Breakdown Voltage	-100	—	V	V_{GS} = 0V, I_D = -1.0 mA
$V_{GS(th)}$	Gate Threshold Voltage ④	-2.0	-4.0		V_{GS} = V_{DS}, I_D = -1.0 mA
I_{GSS}	Gate-to-Source Leakage Forward	—	-100	nA	V_{GS} = -20V
I_{GSS}	Gate-to-Source Leakage Reverse	—	100		V_{GS} = 20V
I_{DSS}	Zero Gate Voltage Drain Current	—	-25	µA	V_{DS} = 0.8 x Max Rating, V_{GS} = 0V
$R_{DS(on)1}$	Static Drain-to-Source ④ On-State Resistance One	—	0.087	Ω	V_{GS} = -12V, I_D = -22A
V_{SD}	Diode Forward Voltage ④	—	-3.3	V	T_C = 25°C, I_S = -35A,V_{GS} = 0V

Table 2. High Dose Rate ⑧

Parameter		10^{11} Rads (Si)/sec Min.	Typ	Max.	10^{12} Rads (Si)/sec Min.	Typ.	Max.	Units	Test Conditions
V_{DSS}	Drain-to-Source Voltage	—	—	-80	—	—	-80	V	Applied drain-to-source voltage during gamma-dot
I_{PP}		—	-100	—	—	-100	—	A	Peak radiation induced photo-current
di/dt		—	-800	—	—	-160	—	A/µsec	Rate of rise of photo-current
L_1		0.1	—	—	0.5	—	—	µH	Circuit inductance required to limit di/dt

Table 3. Single Event Effects ⑨

Parameter	Typ.	Units	Ion	LET (Si) (MeV/mg/cm²)	Fluence (ions/cm²)	Range (µm)	V_{DS} Bias (V)	V_{GS} Bias (V)
BV_{DSS}	-100	V	Ni	28	1 x 10^5	~41	-100	5

IRHM9160 Device

Radiation Characteristics

① Repetitive Rating; Pulse width limited by maximum junction temperature.
Refer to current HEXFET reliability report.

② @ V_{DD} = -25V, Starting T_J = 25°C,
E_{AS} = [0.5 * L * (I_L^2) * [BV_{DSS}/(BV_{DSS}-V_{DD})]
Peak I_L = -35A, V_{GS} = -12V, 25 ≤ R_G ≤ 200Ω

③ I_{SD} ≤ -35A, di/dt ≤ 170 A/µs,
V_{DD} ≤ BV_{DSS}, T_J ≤ 150°C
Suggested RG = 2.35Ω

④ Pulse width ≤ 300 µs; Duty Cycle ≤ 2%

⑤ K/W = °C/W
W/K = W/°C

⑥ **Total Dose Irradiation with V_{GS} Bias.**
-12 volt V_{GS} applied and V_{DS} = 0 during irradiation per MIL-STD-750, method 1019.

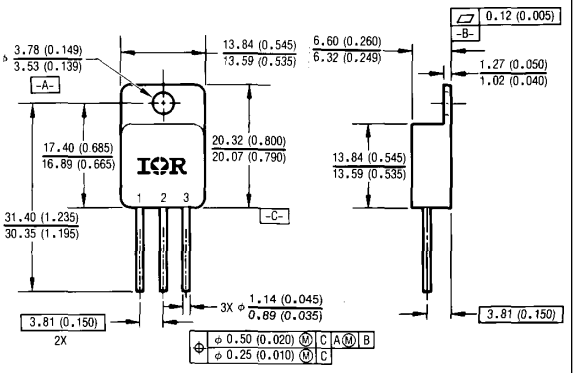
⑦ **Total Dose Irradiation with V_{DS} Bias.**
V_{DS} = 0.8 rated BV_{DSS} (pre-radiation) applied and V_{GS} = 0 during irradiation per MIL-STD-750, method 1019.

⑧ This test is performed using a flash x-ray source operated in the e-beam mode (energy ~2.5 MeV), 30 nsec pulse.

⑨ Process characterized by independent laboratory.

⑩ All Pre-Radiation and Post-Radiation test conditions are **identical** to facilitate direct comparison for circuit applications.

Case Outline and Dimensions

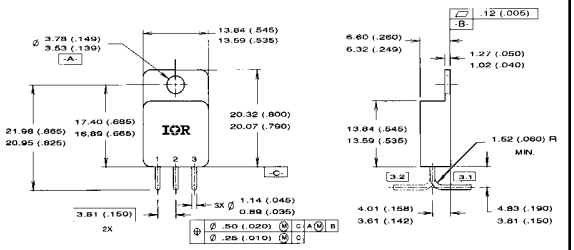


Legend
1 - Drain
2 - Source
3 - Gate

Notes:
1. Dimensioning and Tolerancing per ANSI Y14.5M-1982
2. All dimensions are shown in millimeters (inches).

Conforms to JEDEC Outline TO-254AA
Dimensions in Millimeters and (Inches)

Optional leadforms for outline TO-254



Legend
1 - Drain
2 - Source
3 - Gate

Notes:
1. Dimensioning and Tolerancing per ANSI Y14.5M-1982
2. All dimensions are shown in millimeters (inches).
3. Leadform is available in either orientation:
Example: 3.1 IRHM7160D
3.2 IRHM7160U

CAUTION

BERYLLIA WARNING PER MIL-PRF-19500

Packages containing beryllia shall not be ground, sandblasted, machined, or have other operations performed on them which will produce beryllia or beryllium dust. Furthermore, beryllium oxides packages shall not be placed in acids that will produce fumes containing beryllium.

WORLD HEADQUARTERS: 233 Kansas St., El Segundo, California 90245, Tel: (310) 322 3331
EUROPEAN HEADQUARTERS: Hurst Green, Oxted, Surrey RH8 9BB, UK Tel: ++ 44 1883 732020
IR CANADA: 7321 Victoria Park Ave., Suite 201, Markham, Ontario L3R 2Z8, Tel: (905) 475 1897
IR GERMANY: Saalburgstrasse 157, 61350 Bad Homburg Tel: ++ 49 6172 96590
IR ITALY: Via Liguria 49, 10071 Borgaro, Torino Tel: ++ 39 11 451 0111
IR FAR EAST: K&H Bldg., 2F, 3-30-4 Nishi-Ikeburo 3-Chome, Toshima-Ki, Tokyo Japan 171 Tel: 81 3 3983 0086
IR SOUTHEAST ASIA: 315 Outram Road, #10-02 Tan Boon Liat Building, Singapore 0316 Tel: 65 221 8371